

**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q84137

Shinichi ISHIBASHI, et al.

Appln. No.: 10/510,916

Group Art Unit: 1795

Confirmation No.: 7320

Examiner: Stephen D. Rosasco

Filed: October 12, 2004

For: REFLECTIVE MASK BLANK, REFLECTIVE MASK AND METHODS OF  
PRODUCING THE MASK BLANK AND THE MASK

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This responds to the Restriction Requirement, dated December 18, 2007. In response to the Restriction Requirement, Applicant elects Group I, claims 1-23 and 30-44 for examination. This election is made without traverse.

Applicant reserves the right to file a Divisional Application directed to non-elected claims 24-29.

The USPTO is directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

*/Alan J. Kasper/*

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Date: January 14, 2008